COATING APPLICATION-SPECIFIC SOLUTIONS



COATING

SwissOptic AG, a company of the Jenoptik Group, produces sophisticated coatings for various applications. The spectral range extends from UV (190 nm) to the infrared range (6 μ m, metal mirror up to 12 μ m). In addition, we also develop customized solutions and advise you. Environmental- and stress tests of the coatings for the qualification are carried out in-house.

SUBSTRATE

Typical substrates are:

- Wide variety of optical and colored glasses
- Flat glass, lenses and prisms
- Sapphire, quartz as well as glass ceramic and ceramic
- Infrared materials such as silicon, germanium and zinc sulfide (ZnS)
- Plastic limited to Zeonex
- Substrate size up to 400 x 1,000 mm, Ø 400 mm
- Contract coating on customer substrates on request

SPECIFICATIONS*

General

Wavelength ranges for:

5 5	
Metallic mirror	120 nm-12 µm
Dielectric mirror	190 nm-3 µm
Filter, beam splitter, black chrome	250
nm-3µm	
Anti reflection coatings	190 nm-5 µm
Conductive layers	400 nm-1.6 μm
Angle of incidence ranges	0–45° typical
	0-85° nossihle

U-85° possible
 All polarization types are specifiable (p, s and average value)

- All polarization types are spectratile (p, s and ave
 Reflection, transmission and optical density
- Phase specification
- Very high LIDT for Pulse and CW laser applications

Mirrors

- Metallic, dielectric and hybrid mirrors
- Narrowband and broadband mirrors
- Front and back surface mirror
- Reflection to 99.9 % possible
- Laser mirrors for one or more wavelengths

Antireflection coatings

- Narrow, multi- and wide-band spectral ranges
- Residual reflection to < 0.1 % possible</p>

Filters

- Edge Filters: Long- (LWP) and short pass (SWP)
- Edge position tolerance from 0.5 % of the nominal wavelength
- Narrowband filter (T-band) and Notch filters (R-band)
- Center position tolerance from 0.2 % of the nominal wavelength
- High peak transmittance and high blocking possible
- Half width from 2 % of the nominal wavelength
- Laser protection filter
- Single and multi-band filters with freely definable widths and positions
- Graduated variable filters

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Beam splitters

- Available on a plane-parallel plate or embedded in a cube:
 - Cemented
 - Optically contacted
 - With defined airspace
- Polarizing beam splitter (PBS)
- Non-polarizing beamsplitter (NPBS)
- Neutral beam splitter
- Narrow, wide or multiple spectral regions with freely definable splitting ratios

Transparent and electrically conductive layers (ITO)

- \blacktriangleright Defined electrical resistance, tolerance ±20 %
- Lowest specification < 17 Ω/cm^2 for EMI protection
- Transmission > 80 % in the visible range and > 40 % at 1,550 nm
- ▶ Low reflection < 20 % possible
- Structuring with mechanical masks
- Metal contact electrodes

Absorbing layers

- Typically made with black chrome layers
- Chrome-free absorber layers available
- High blocking, low reflection
- Narrow- and broadband
- Efficient from air and/or glass sides
- Structurable (etch and lift-off processes)

Layers for non-optical applications

- Barrier layers, e. g. etch stop
- Layers to connect components
- Conductive layers

Development of customized coatings

Surface imperfections

- Assessment according to ISO 10110/MIL-0-13830A/DIN3140
- Specifications depending on the layer system e.g.:
 - AR: 5/C3 x 0.025 over Ø 25 mm (MIL 20/10)
 - Filter: 5/C3 x 0.040 over Ø 25 mm (MIL 40/20)

* The following error and tolerance data indicate possible limit values.

